

Recommendation

FIFRA SECTION 2(ee) RECOMMENDATION

GROUP 28 INSECTICIDE

Shenzi 400 SC Insecticide

(EPA Reg. No. 70506-607)

FOR SUPPRESSION OF LEAFMINER IN SUGAR BEETS IN, CO, ID, MI, MT, ND, NE, OR, SD, WA & WY ONLY.

This recommendation is made as permitted under FIFRA Section 2(ee) and has not been submitted to or approved by USEPA.

DIRECTIONS FOR USE

It is a violation of Federal law to use this product in a manner inconsistent with its labeling. Read and follow all applicable instructions, restrictions, and precautions, and Conditions of Sale and Warranty on the EPA-approved label. This recommendation and the federally registered label must be in the possession of the user at the time of pesticide application.

CROP	APPLICATION METHOD	INSECT	SHENZI 400 SC INSECTICIDE RATE PER ACRE IN FL OZ (LB A.I.)	RE- TREATMENT INTERVAL IN DAYS (RTI)	PRE- HARVEST INTERVAL IN DAYS (PHI)	RE-ENTRY INTERVAL IN HOURS (REI)
Sugar beet	Foliar	Leafminer	1.7-2.5 (0.044 - 0.098)	3	1	4

APPLICATIONS INSTRUCTIONS:

SHENZI 400SC Insecticide is recommended for suppression of sugar beet leafminer(Pegomya betae)in sugar beet grown for sugar and for seed.

For best results, make applications before populations exceed treatment thresholds. Follow local university recommendations for treatment thresholds and best timing.

Thorough spray coverage is essential for best performance.

Adjuvants such as methylated seed oil (MSO) should be added for improved coverage and residual.

RESTRICTIONS:

- Do not apply more than 7.7 fl oz SHENZI 400SC Insecticide insect control or 0.2 lb ai of chlorantraniliprole containing products per acre per crop.
- Do not apply more than 30.8 fl oz SHENZI 400SC Insecticide or 0.8 lb. a.i. of chlorantraniliprole containing products per acre per calendar year.
- Do not make more than 4 applications per acre per crop or 16 applications per acre per calendar year.

See the RESISTANCE MANAGEMENT section of the SHENZI 400SC Insecticide insect control Section 3 Federal label for additional guidance on insecticide resistance management.